| Electronic Patent A | ٩рр | olication Fe | e Transı | mittal | | |
|--|-------------------------------------|--|----------|--------|-------------------------|--|
| Application Number: | 10 | 10519998 | | | | |
| Filing Date: | 05-Jan-2005 | | | | | |
| Title of Invention: | Pł | Photoresist resin and photoresist resin composition Shigeki Kambara Mark Sandler Weiner/Patricia Siegel 3273-0196PUS1 | | | | |
| First Named Inventor/Applicant Name: | SI | Shigeki Kambara | | | | |
| Filer: | Mark Sandler Weiner/Patricia Siegel | | | | | |
| Attorney Docket Number: | 3273-0196PUS1 | | | | | |
| Filed as Large Entity | | | | | | |
| U.S. National Stage under 35 USC 371 Fil | ing | Fees | | | | |
| Description | | Fee Code | Quantity | Amount | Sub-Total in USD(\$) | |
| Basic Filing: | | | | | | |
| Pages: | | | | | | |
| Claims: | | | | | | |
| Miscellaneous-Filing: | | | | | | |
| Petition: | | | | | | |
| Patent-Appeals-and-Interference: | | | | | | |
| Post-Allowance-and-Post-Issuance: | | | | | | |
| Extension-of-Time: | | | | | | |
| Extension - 1 month with \$0 paid | | 1251 | 1 | 120 | 120 | |

| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) |
|----------------|-------------------|----------|--------|-------------------------|
| Miscellaneous: | | | | |
| | Total in USD (\$) | | | 120 |